

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Ching-Tien Ma

Group Art Unit: 1756

Serial No.: 10/038,800

Examiner: Nicole M. Barreca

Filed:

Dec. 31, 2001

In Response to Office Action

Dated:

June 18, 2003

For:

Method for Forming Via and Contact Holes with

Deep UV Photoresist

Attorney Docket No.: 67,200-549

Certificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450

Dixon

Date:

October 20, 2003

RESPONSE TO OFFICE ACTION

Commissioner for Patents Alexandria, VA 22313-1450

Dear Sir:

In response to an Office Action mailed June 18, 2003, please enter the following amendments and consider the following remarks. The Commissioner is authorized to charge Deposit Account No. 50-0484 the fee for the one-month extension of time.